

# EIPBN 2014 - Symposium on Lithography and Nanofabrication

## Veranstaltung - EIPBN 2014 - Symposium on Lithography and Nanofabrication

---

|              |                                                           |
|--------------|-----------------------------------------------------------|
| <b>Titel</b> | EIPBN 2014 - Symposium on Lithography and Nanofabrication |
| <b>Wann</b>  | Di, 27. Mai 2014 - Fr, 30. Mai 2014                       |

## Beschreibung

---

The World's Leading Symposium on Lithography and Nanofabrication

**EIPBN 2014 - Conference** is the premier conference on the science and technology of nanopatterning. Traditionally focused on electron, ion, and photon beams, (the 3 beams), the technology of nanofabrication covered in this conference has grown to include nanoimprint and molecular self-assembly as well. This conference is the place to hear the newest techniques and the latest advances in patterning and device fabrication technology.

Please find more information relating this event by following link:

<http://eipbn.org/>

## Lokalität - Washington DC

---

|                 |                               |
|-----------------|-------------------------------|
| <b>Standort</b> | <a href="#">Washington DC</a> |
| <b>Ortsname</b> | Washington DC                 |
| <b>Land</b>     | US                            |